EAST Search History

Ref#	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	610	(polishing near5 composition near5 method).ti.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 13:25
S2	1536	uotani.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 13:26
S3	342622	takahashi.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 13:26
S4	417420	sato.in.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 13:26
S5	751361	S2 S3 S4	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 13:26
S6	24	S5 and S1	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 13:26
S7	6	S5 and (azole same oxidizing same amino)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 13:28
S8	1	WO-03068883-\$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 14:44
S9	0	S8 and oxidixing and amino and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 14:45
S10	0	S8 and oxidizing and amino and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 14:45
S11	2	("6776810").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/12/15 14:46
S12	1	S11 and oxidizing and amino and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 14:46

S13	2	EP-1118647-\$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:14
S14	0	S13 and oxidizing and amino and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:15
S15	0	S13 and (oxidizing or oxidizer) and amino and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:15
S16	3373	(oxidizing or oxidizer) and amino and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:15
S17	169	(polishing or planarizing or planarization or abrading or abrasion).ti. and (oxidizing or oxidizer) and amino and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:16
S18	1	WO-02067309-\$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:16
S19	0	S18 and oxidizing and amino and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:16
S20	0	S18 and (oxidizing or oxidizer) and amino and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:16
S21	14	(polishing or planarizing or planarization or abrading or abrasion).ti. and (oxidizing or oxidizer) and amino and azole same molecular near4 weight	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:50
S22	15	(polishing or planarizing or planarization or abrading or abrasion).ti. and azole same molecular near4 weight	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:52
S23	16	(polishing or planarizing or planarization or abrading or abrasion).ab. and azole same molecular near4 weight	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:52
S24	16	(polishing or planarizing or planarization or abrading or abrasion).ab. and (azole same molecular near4 weight)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:52

S25	3	(polishing or planarizing or planarization or abrading or abrasion).ti. and azole same molecular near4 mass	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:54
S26	236	(polishing or planarizing or planarization or abrading or abrasion) same azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:54
S27	18	(polishing or planarizing or planarization or abrading or abrasion) same azole same molecular	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:54
S28	662	(polishing or planarizing or planarization or abrading or abrasion).ab. and amino same (glycine or alanine or aminobutyric or proline or phenylanaline or sarcosine or ornithine or leucine or valine or norvaline or thyroxine or lanthionine or ethionine or methionine or cycteine or tyrosine or homoserine or threonine or serine or glutamine or azaserine or arginine or lysine or histidine or ergothioneine or tryptophan)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:57
\$29	592	(polishing or planarizing or planarization or abrading or abrasion).ab. and amino near3 acid same (glycine or alanine or aminobutyric or proline or phenylanaline or sarcosine or ornithine or leucine or valine or norvaline or thyroxine or lanthionine or ethionine or methionine or cycteine or tyrosine or homoserine or threonine or serine or glutamine or azaserine or arginine or lysine or histidine or ergothioneine or tryptophan)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:58

S30	165	(polishing or planarizing or planarization or abrading or abrasion).ab. and amino near3 acid same (glycine or alanine or aminobutyric or proline or phenylanaline or sarcosine or ornithine or leucine or valine or norvaline or thyroxine or lanthionine or ethionine or methionine or cycteine or tyrosine or homoserine or threonine or serine or glutamine or azaserine or arginine or canavanine or citrulline or lysine or histidine or ergothioneine or tryptophan) same (chelating or enhance)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 15:59
S31	2	("20020173221").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/12/15 16:14
S32	1	S31 and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 16:14
S33	1	S31 and surfactant	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 16:20
S34	4	(("6776810") or ("20020173221")).PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/12/15 16:38
S35	1	S34 and ((film near3 forming) or "film-forming")	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 16:38
S36	13915	(polishing or planarizing or planarization or abrading or abrasion).ab. and (alakli or alkaline or polyamine or ammonia)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 16:57
S37	3278	(polishing or planarizing or planarization or abrading or abrasion).ab. and (alakli or alkaline or polyamine or ammonia) same ("%" or amount)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 16:57
S38	880	(polishing or planarizing or planarization or abrading or abrasion).ab. and (alakli or alkaline) same ("%" or amount)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 16:57

S39	46	(polishing or planarizing or planarization or abrading or abrasion).ab. and (alakli or alkaline) near3 (component or substance) same ("%" or amount)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 16:57
S 40	12	(polishing or planarizing or planarization or abrading or abrasion).ab. and (alakli or alkaline) near3 (component or substance) with (enhanc \$4 or improv\$4 or impart\$4 or effective or effect or increas\$4 or decreas\$4 or benefit or better or exhibit or prefer or preferred or effective) same ("%" or amount)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 17:04
S41	101	(polishing or planarizing or planarization or abrading or abrasion) same (alakli or alkaline) near3 (component or substance) same ("%" or amount)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 17:11
S42	43	(polishing or planarizing) same (alakli or alkaline) near3 (component or substance) same ("%" or amount)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/15 17:11
S43	90734	(surfactant or (surface near2 active) or "surface-active") same (alkylaromatic or sulfonic or polyoxyethylene or phosphoric)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:15
S44	693	(surfactant or (surface near2 active) or "surface-active") same (alkylaromatic or sulfonic or polyoxyethylene or phosphoric) and polishing. ti.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:15
S45	1892	438/427.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:16
S46	6144	51/307-309.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:16
S47	2561	451/5.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:16

S48	1093	106/3.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:16
S49	1136	216/99.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:16
S50	1030	216/101-102.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:16
S51	13337	S45 S46 S47 S48 S49 S50	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:17
S52	132	S51 and S44	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 09:17
S53	15	(surfactant or (surface near2 active) or "surface-active") same ((alkylaromatic near3 sulfonic) or (polyoxyethylene near3 phosphoric) or (alkyl near3 phosphoric near2 acid)) and polishing.ti.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 10:10
S54	13919	(alkali ro alkaline or polyamine or ammonia) same polishing	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 10:18
S55	988	(alkali ro alkaline or polyamine or ammonia) same polishing and S51	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 10:18
S56	682	(alkali ro alkaline or polyamine or ammonia) and polishing.ti. and S51	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 10:20
S57	296	(alkali ro alkaline or polyamine or ammonia) near10 (substance or component or compound) and polishing.ti. and S51	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 10:20
S58	252	(alkali ro alkaline or polyamine or ammonia) near5 (substance or component or compound) and polishing.ti. and S51	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 10:38

S59	109	(alkali ro alkaline or polyamine or ammonia) near5 (substance or compound) and (polishing near composition).ti. and S51	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 10:39
S60	0	(azole with vinyl with "water- soluble") and (polishing near composition).ti. and S51	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:15
S61	0	(azole with vinyl with "water- soluble") and (polishing near composition).ti.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:15
S62	4	(azole with vinyl with "water- soluble") and polishing.ti.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:15
S63	5	(azole with "water-soluble" same vinyl) and polishing.ti.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:15
S64	11	(azole with "water-soluble" same vinyl)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:16
S65	11	(azole\$4 with "water-soluble" same vinyl)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:18
S66	107	(((benzotriazole or triazole or azole\$4) with "water-soluble" same vinyl)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:19
S67	94	((benzotriazole or triazole or azole\$4) with "water-soluble" with vinyl)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:19
S68	716	azole with polymer	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:24
S69	44	azole with polymer with ("water-soluble" or (water near soluble))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/16 11:25
S70	2	("5976414").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/12/16 11:39

S71	92626	fatty near acid same (surfactant or (surface near active))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 12:58
S72	0	fatty near acid same (surfactant or (surface near active)) and (polishing or CMP) near3 composiiton	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 12:58
S73	626	fatty near acid same (surfactant or (surface near active)) and (polishing or CMP) near3 composition	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 12:58
S74	89	fatty near acid same (surfactant or (surface near active)) and ((polishing or CMP) near3 composition).ti.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 12:58
S75	60	fatty near acid same (surfactant or (surface near active)) and ((polishing or CMP) near3 composition).ti. and (silica or alumina or titania or titanium)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 13:16
S76	14	fatty near acid same (surfactant or (surface near active)) and ((polishing or CMP) near3 composition).ti. and (silica or alumina or titania or titanium) and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 13:16
S77	40	fatty near acid same (surfactant or (surface near active)) and ((polishing or CMP) near3 composition).ti. and (silica or alumina or titania or titanium) and (triazole or benzotriazole or azole)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 13:17
S78	2	("5976414").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/12/19 15:29
S79	0	((polyvinyl near tetrazole) or (poly near vinyl near tetrazole)) and (polishing or CMP) near3 composition	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 15:35
S80	24	((polyvinyl near tetrazole) or (poly near vinyl near tetrazole))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 15:36
S81	0	((polyvinyl near tetrazole) or (poly near vinyl near tetrazole)) and (polishing or abrading or planarizing or planarization)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 15:36

S82	12163	vinylimidazole or (vinyl near imidazole) or "vinyl- imidazole"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 15:39
S83	43	(vinylimidazole or (vinyl near imidazole) or "vinyl- imidazole") and (polishing or CMP) near3 composition	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 15:39
S84	2	("6410497").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/12/19 16:02
S85	0	S84 and (beleach near stabilizers)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 16:02
S86	1	S84 and (bleach near stabilizers)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 16:02
S87	1	(vinylimidazole or (vinyl near imidazole) or "vinyl- imidazole") and (polishing or CMP) near3 composition and (bleach near stabilizers)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 16:02
S88	1892	438/427.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:09
S89	6148	51/307-309.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:09
S90	2561	451/5.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:09
S91	1093	106/3.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:09
S92	1136	216/99.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:09
S93	1030	216/101-102.ccls.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:09
S94	13341	S88 S89 S90 S91 S92 S93	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:09

S95	1	S94 and vinyl near5 azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:09
S96	2	("20070082456").PN.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	OFF	2008/12/19 17:13
S97	2	S96 and azole with vinyl	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:13
S98	621	(polymerization or polymerize) with (vinylimidazole or (vinyl near imidazole))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:19
S 99	786	(polymerization or polymerize) same (vinylimidazole or (vinyl near imidazole)) same ((acrylic near acid) or (methacrylic near acid) or (methyl near acrylate))	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:19
S100	972	(polymerization or polymerize) same (vinylimidazole or (vinyl near imidazole)) same ((acrylic near acid) or (methacrylic near acid) or (methyl near acrylate) or (vinyl near acetate) or styrene or acryloylmorpholine)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:20
S101	85509	(polymerization or polymerize) same (vinylimidazole or (vinyl near imidazole)) same ((acrylic near acid) or (methacrylic near acid) or (methyl near acrylate) or (vinyl near acetate) or styrene or acryloylmorpholine) and polishing or CMP	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:20
S102	9	(polymerization or polymerize or polymerize or polymerizing) same (vinylimidazole or (vinyl near imidazole)) same ((acrylic near acid) or (methacrylic near acid) or (methyl near acrylate) or (vinyl near acetate) or styrene or acryloylmorpholine) and (polishing or CMP)	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/19 17:20

S103	1	WO-02067309-\$.did.	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/22 09:14
S104	0	S103 and vinyl	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/22 09:15
S105	0	S103 and "1-vinylimidazole"	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	{	2008/12/22 09:15
S106	0	S103 and azole	US-PGPUB; USPAT; USOCR; EPO; JPO; DERWENT	OR	ON	2008/12/22 09:15

12/22/2008 9:22:59 AM

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